In the Claims:

- 1. (Cancelled)
- 2. (Currently Amended) The barrier film according to claim 1, wherein A barrier film comprising a base material film and a barrier layer deposited on at least one side surface of the base material film,

wherein the barrier layer comprises a water repellent layer and a dense layer,

the water repellent layer is a silicon oxide carbide film having the atomic percent of Si:O:C in a range of 100:40 to 120:80 to 160, and the thickness in a range of 2 to 300 nm,

the dense layer is a silicon oxide carbide film having the atomic percent of Si:O:C in a range of 100:100 to 200:5 to 100, and the thickness in a range of 5 to 300 nm,

the base material film is a resin film having the thickness in a range of 5 μ m to 500 μ m, and

the barrier layer has a laminated structure comprising the dense layer sandwiched between two water repellent layers.

3. (Currently Amended) The barrier film according to claim 1, wherein A barrier film comprising a base material film and a barrier layer deposited on at least one side surface of the base material film,

wherein the barrier layer comprises a water repellent layer and a dense layer,

the water repellent layer is a silicon oxide carbide film having the atomic percent of Si:O:C in a range of 100:40 to 120:80 to 160, and the thickness in a range of 2 to 300 nm,

the dense layer is a silicon oxide carbide film having the atomic percent of Si:O:C in a range of 100:100 to 200:5 to 100, and the thickness in a range of 5 to 300 nm,

the base material film is a resin film having the thickness in a range of 5 μ m to 500 μ m, and

the barrier layer has a laminated structure comprising [[the]]the water repellent layer sandwiched between two dense layers.

- 4. (Cancelled)
- 5. (Currently Amended) The barrier film according to claim [[1]]2, wherein the barrier layer is a silicon oxide carbide film wherein the dense layer is sandwiched between two water repellent layers, with the atomic percent of O (oxygen) with respect to Si (silicon) reduced continuously from the central part in the thickness direction toward the both outer sides and the atomic percent of C (carbon) with respect to Si (silicon) increased from the central part toward the both outer sides in the thickness direction.
- 6. (Currently Amended) The barrier film according to claim [[1]]3, wherein the barrier layer is a silicon oxide carbide film wherein the water repellent layer is sandwiched between two dense layers, with the atomic percent of O (oxygen) with respect to Si (silicon) increased continuously from the central part toward the both outer sides in the thickness direction and the atomic percent of C (carbon) with respect to Si (silicon) reduced from the central part toward the both outer sides.
 - 7. (Cancelled)
 - 8. (Cancelled)
- 9. (Currently Amended) The barrier film according to claim [[1]]2, wherein the barrier layer is laminated by two or more layers.
- 10. (Currently Amended) The barrier film according to claim [[1]]2, wherein a plasma treatment process is applied to the uppermost surface of the barrier layer.
- 11. (Currently Amended) The barrier film according to claim [[1]]2, wherein the barrier layer is deposited on the base material film via a resin layer.

- 12. (Currently Amended) The barrier film according to claim [[1]]2, wherein a resin layer is deposited on the barrier layer.
- 13. (Currently Amended) The barrier film according to claim [[1]]2, wherein the oxygen transmission rate (OTR) is 3 cc/m²/day atm or less, and the water vapor transmission rate (WVTR) is 3 g/m²/day or less.
- 14. (Currently Amended) A laminated material comprising a heat sealable resin layer deposited on at least one side surface of the barrier film according to claim [[1]]2.
- 15. (Original) A packaging container using the laminated material according to claim 14, produced by thermally fusing the heat sealable resin layer into a bag or a box.
- 16. (Currently Amended) An image display medium using the barrier film according to claim [[1]]2.
- 17. (New) The barrier film according to claim 3, wherein the barrier layer is laminated by two or more layers.
- 18. (New) The barrier film according to claim 3, wherein a plasma treatment process is applied to the uppermost surface of the barrier layer.
- 19. (New) The barrier film according to claim 3, wherein the barrier layer is deposited on the base material film via a resin layer.
- 20. (New) The barrier film according to claim 3, wherein a resin layer is deposited on the barrier layer.
- 21. (New) The barrier film according to claim 3, wherein the oxygen transmission rate (OTR) is $3 \text{ cc/m}^2/\text{day}$ atm or less, and the water vapor transmission rate (WVTR) is $3 \text{ g/m}^2/\text{day}$ or less.

- 22. (New) A laminated material comprising a heat sealable resin layer deposited on at least one side surface of the barrier film according to claim 3.
- 23. (New) A packaging container using the laminated material according to claim 22, produced by thermally fusing the heat sealable resin layer into a bag or a box.
- 24. (New) An image display medium using the barrier film according to claim 3.